



INFORMATION DISCLOSURE CITATION PTO-1449	Atty. Docket No. 000593B	Serial No. 10/615,381
	Applicant(s): NISHIUCHI, et al.	
	Filing Date: July 9, 2003	Group Art Unit: 1763

U.S. PATENT DOCUMENTS

Examiner Initial	Document No.	Name	Date	Class	Subclass	Filing Date (If appropriate)
AA	4,581,113	Morimoto et al.	04-08-1986	204	192	
AB	4,534,840	Shindo et al.	08-13-1985	204	192	
AC	4,837,114	Hamada et al.	06-06-1989	427	127	
AD						
AE						

FOREIGN PATENT DOCUMENTS

	Document No.	Date	Country	Translation (Yes or No)
AF	EP 0 104 916	04-04-1984	EPO	
AG	EP 0 811 994	12-10-1997	EPO	
AH				
AI				
AJ				

Examiner	Date Considered
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IDS not considered
- Richard Bush



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OTHER DOCUMENTS

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	AL	Dhere et al.: "PURITY AND MORPHOLOGY OF ALUMINUM FILMS," <i>Thin Solid Films</i> , Switzerland, Vol. 30, No. 2, December 1975, pp. 267-279.
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Examiner

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